Microstructure and Thermomechanical Properties of Polyimide-Silica Nanocomposites

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Novel polyimide-silica nanocomposites with interphase chemical bonding have been prepared using the sol-gel process. The morphology, thermal and mechanical properties were studied as a function of silica content and compared with the similar composites having no interphase interaction. The polyimide precursors, polyamic acids (PAAs) with or without pendant hydroxyl groups were prepared from the reaction of pyromellitic dianhydride with a mixture of oxdianiline and 1,3 phenylenediamine or 2,4-dimochinophenol in dimethylacetamide. The PAA with pendant hydroxyl groups was reacted with isocyanatopropyltriethoxysilane to produce alkoxy groups on the chain. The reinforcement of PAA matrices with or without alkoxy groups on the chain was carried out by mixing appropriate amount of tetraethoxysilane (TEOS) and carrying out its hydrolysis and condensation in a sol-gel process. Thin hybrid films were imidized by successive heating up to 300°C. The presence of alkoxy groups on the polymer chain and their cocondensation with TEOS developed the silica network which was interconnected chemically with the polyimide matrix. SEM studies show a drastic decrease in the silica particle size in the chemically bonded system. Higher thermal stability and mechanical strength, improved transparency, and low values of thermal coefficient of expansion were observed in case of chemically bonded composites.

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1. INTRODUCTION

Composites where nanoscale inclusions are imbedded within matrix material have attracted increasing research attention in recent years. Reviews on such composites using nanoclays [1, 2], nanotubes [3, 4], and inorganic networks [5–7] are available in literature. The inorganic networks are usually prepared by the sol-gel process [7, 8] to synergistically combine the properties of organic polymers (e.g., toughness, ductility, and processability) with that of ceramic materials (e.g., heat resistance, low thermal expansion, and retention of mechanical properties at high temperatures) [9, 10].

Polyimides (PIs) are extensively used in microelectronics and aerospace industries owing to their excellent thermal, mechanical, and dielectric properties [11]. However, PIs exhibit relatively high value of water absorption and the coefficient of thermal expansion, which can limit their application in the field of electronics. Composites from PIs and silica offering favorable properties of the both are therefore in great demand and further improvement in these can be achieved by bringing the dispersion of reinforced inorganic material to nanolevel in the matrix. The compatibility between PIs and silica generated in the sol-gel process using different tetraalkoxy silanes in the hybrids, however, is not as good as expected because of weak interactions between the pure organic and inorganic phases [12]. Tendency of the silica network to agglomerates into large particles at higher silica loading ultimately leads to phase separation. Since the morphology of two-phase systems affects the mechanical properties of polymer hybrids, attempts have been made to improve the compatibility between PIs and silica by increasing interfacial interactions. Wang et al. [13, 14], Schrotter et al. [15] Chen and Iroh [16], Xenopoulos et al. [17], Musto et al. [18], and Chang et al. [19] have used different organosilanes with tetraalkoxy silane to produce silica network in the PI matrix. The organic groups present on these silanes, for example, aminophenyl-trimethoxysilane, aminopropyl-trimethoxysilane, diaminophenyltetramethyl-disiloxane, glycidyloxy-propyltrimethoxysilane, aminopropylmethyl-diet-hoxysilane, and dianinopropyltetramethyl-disiloxane, are supposed to interact with organic PAA chain and alkoxy groups during the sol-gel process become the part of the silica network.

Present authors [20, 21] have found that the introduction of hydroxyl groups on the backbone of polymer chain can have a positive effect through physical or chemical
interactions between organic and inorganic components. The morphology of silica particle produced in such matrices is totally different and particle size is much smaller for the same silica contents as compared to simple matrix without hydroxyl groups and this has a positive influence on the thermal and mechanical properties of the resulting hybrids.

The reaction of hydroxyl groups on the polymer chain, however, is very slow with the alkoxy groups of TEOS and in the sol-gel process usually a physical bonding between the matrix and the silica network can be achieved. Also the Si–O−C bonds formed by the reaction of hydroxyl groups on the polymer chain and the alkoxy groups from the silane during the sol-gel process are considered very weak. In the present work, the PAA chains containing pendant hydroxyl groups synthesized from the reaction of pyromellitic dianhydride (PMDA) with a mixture of oxydianiline (ODA) and 2,4-diminophenol (2,4-DAP) were reacted with isocyanato-hydride (PMDA) with a mixture of oxydianiline (ODA) and 2,4-diminophenol (2,4-DAP) were reacted with isocyanato- propyltriethoxysilane (ICTEOS) to produce pendant alkoxy groups on the chain. The number of pendant alkoxy groups on PAA chain could be varied by changing the proportion of 2,4-DAP in the total diamine content in the reaction mixture. The reaction of isocyanato group with the –OH group leading to a polyurethane linkage is considered as very fast. On addition of an appropriate amount of TEOS, the sol-gel process was carried out to produce an extensively bonded silica network in the matrix. Phase compatibilization to reduce the agglomerate tendencies in the inorganic phase is thus achieved by chemical reaction between the matrix having alkoxy groups and those of TEOS. The PAA with no hydroxyl groups on the chain was prepared by the reaction of a mixture of 1,3-phenylenediamine (1,3-DAB) and oxydianiline (ODA) in dimethylacetamide (DMAc) with equimolar amount of pyromellitic dianhydride (PMDA) and this acts as control system. The resulting hybrid films in both cases were imidized. The morphology, thermal stability, visco-elastic and thermal mechanical properties of the PI-silica hybrid films were studied and related with the amount of silica and the extent of chemical bonding between the organic and inorganic phases.

2. EXPERIMENTAL

2.1. Materials

The monomers used to synthesize the polyimide were pyromellitic dianhydride (PMDA), 4,4’-oxydianiline (ODA), 1,3-diaminobenzene (1,3-DAB). These monomers and tetraethoxysilane (TEOS), triethylamine (TEA), were of analytical grade obtained from Aldrich. The solvent anhydrous DMAc (water contents ≤ 0.05 wt%) kept over molecular sieve was obtained from Aldrich. Diaminophenol-dihydrochloride (2,4-DAP·2HCl) was obtained from Fluka and it was purified to remove HCl from the salt using TEA. Stoichiometric amount of TEA was added to neutralize HCl completely. About 10 g DMAc was then added to the mixture. The mixture was stirred for few minutes and finally filtered under vacuum to remove the precipitates of triethyl ammonium hydrochloride. To this solution of 2,4-DAP, 4.853 g of ODA (23.75 milli mol) and 160 g of solvent were added and stirred thoroughly for complete dissolution. An equimolar amount of PMDA (5.622 g, 0.025 mol) was added to react with the diamines. The reaction mixture was stirred for additional 24 hours to ensure complete reaction. The inherent viscosities of the PI solutions at 25°C were in the range 2.1–2.33 dL/g. Two types of PAA solutions were prepared, one with 5 and other with 10 mole percent of hydroxy amine. The coupling agent ICTEOS was added to the prepared PAA solutions in equimolar amount with 2,4-DAP, that is 5% (or in double amount 10%) by mol and the mixture was stirred at 50°C for 2 hours.

2.2. Preparation of the hybrid films

2.2.1. Preparation of PAA solution

For the preparation of PAA without pendant hydroxy groups on the chain, a mixture of ODA and 1,3-DAB, (0.025 mol) in molar ratio 95 : 5; respectively, was placed into a 250 quickfit flask and dissolved by stirring in 170 g of anhydrous DMAC as solvent. PMDA, (0.025 mol) was added into it under complete anhydrous conditions. The viscosity increased quickly over the next one hour, and the reaction was allowed to proceed at room temperature for 24 hours to ensure a complete reaction.

2.2.2. Preparation of the PAA solution with pendant alkoxy groups

In order to prepare PAA with hydroxy groups on the chain, 1,3-DAB was replaced with 2,4-DAP in the PAA synthesis. As only the salt of this compound was available, it was purified as follows: in a 100 ml glass bottle, 0.254 g of 2,4-DAP·2HCl (1.25 milli mol) was taken. Stoichiometric amount of TEA was added to neutralize HCl completely. About 10 g DMAc was then added to the mixture. The mixture was stirred for few minutes and finally filtered under vacuum to remove the precipitates of triethyl ammonium hydrochloride. To this solution of 2,4-DAP, 4.853 g of ODA (23.75 milli mol) and 160 g of solvent were added and stirred thoroughly for complete dissolution. An equimolar amount of PMDA (5.622 g, 0.025 mol) was added to react with the diamines. The reaction mixture was stirred for additional 24 hours to ensure complete reaction. The inherent viscosities of the PI solutions at 25°C were in the range 2.1–2.33 dL/g. Two types of PAA solutions were prepared, one with 5 and other with 10 mole percent of hydroxy amine. The coupling agent ICTEOS was added to the prepared PAA solutions in equimolar amount with 2,4-DAP, that is 5% (or in double amount 10%) by mol and the mixture was stirred at 50°C for 2 hours.

2.2.3. Sol-gel processing and imidization reaction

Silica network was produced in the above polymer solutions by carrying out the sol-gel process. A measured amount of TEOS was added to the polymer precursor solution with continued stirring until the solution became homogenous. A stoichiometric amount of water as 10 wt% 0.1 N HCl solution in DMAc was then added. The stirring continued for 4 hours at 60°C. Hybrids with various silica contents ranging from 5–40 wt% were prepared and the films (thickness varying from 0.08 to 0.10 mm) were cast by solvent elution at 70°C. These hybrid films were heated for 1 hours at 100°C, 1 hours at 200°C, 0.5 hours at 270°C, and 1 hours at 300°C in sequence to carry out the imidization process [12]. The silica network formation simultaneously took place with the imidization process.

The hybrids from the PI matrix without hydroxyl groups are referred to as PI-Si-T and those with hydroxyl groups having 5% 2,4-DAP mixed with 5% by mol ICTEOS as PISi-P5-I-T while those hybrids containing 10% 2,4-DAP mixed
with 10% by mol ICTEOS are referred to as PISi-P10-I-T. The flow sheet diagram describing the preparation of chemically bonded hybrids is given in Figure 1.

**2.3. Measurements**

The imidization process and the silica network formation in the hybrid films were monitored by the FTIR spectroscopy using a Perkin-Elmer FTIR 2000 spectrophotometer. FTIR analysis was also used to confirm the formation of chemical bonds between the organic matrix and the silica network. For scanning electron microscopy (SEM), the brittle-fractured films were sputter coated with gold by means of Balzer’s SCD-50 sputter coater and then examined by JSM-630 Joel scanning electron microscope operated at 20 kV.

Dynamic mechanical analysis (DMA) was used to measure α-relaxation temperature associated with the glass
transition and the temperature variation of storage modulus of the hybrid material. These measurements were performed under tension mode in the temperature range 100–500°C at 5°C/min ramp using a frequency of 5 Hz under inert atmosphere on a DMA Q-800 (TA, USA).

Thermal mechanical analysis to measure the linear coefficient of thermal expansion was performed on Schimadzu TMA-50 at a heating rate of 10°C/min with an applied load of 4.00 g under nitrogen gas. Thermogravimetry (TG) was performed on approximately 10 mg of the sample from ambient to 800°C at a heating rate of 10°C/min in a dynamic synthetic air atmosphere (30 ml/min), using TGA-50 Shimadzu automatic analyzer.

3. RESULTS AND DISCUSSION

The solutions of the polyamic acid-silica mixtures after the sol-gel process and prior to the film casting were homogeneous in all cases. In the case of PISi-T system, the hybrids films up to 10 wt% silica were transparent and brownish yellow, and those with more than 20% silica were opaque and dark brown in color. In the case of PISi-P5-I-T and PISi-P10-I-T hybrids, films up to 20 wt% silica loading were transparent and dark brown in color. Those with 30–40 wt% silica were semi-transparent and dark brown in color. The optical transparency of the films thus increased as the chemical interaction between the phases reduced the tendency of silica particle to agglomerate. The hybrid films remain transparent so far as the size of these particles is less than the wavelength of light and become opaque when their size increases.

3.1. FTIR spectroscopy

The curing of PAA to PI and the reaction of the pendant hydroxyl groups with the ICTEOS were monitored by FTIR spectroscopy. In case of PAA, the broad band around 1660 cm⁻¹ due to amide I vibrations, and amide II disappeared entirely after the thermal imidization of C=O stretching, C−N stretching, and C−N−C deformation vibrations. A band at 1570–1540 cm⁻¹, known as amide II mode, is a mixed contribution of N−H in plane bending, the C−N stretching, and C−C stretching vibrations. The amide I and amide II disappeared entirely after the thermal imidization, and new strong absorption bands at 1777–1782, 1722–1730, and 1377–1380 cm⁻¹ due to the asymmetric stretching of C=O, symmetric stretching of C=O, and symmetric stretching of C−N, respectively, which are assigned to the imide ring [22]. Appearance of these characteristic absorption bands confirms the curing of PAA to PI. The appearance of absorption peaks at 1100 and 830 cm⁻¹ in the IR spectra of PISi-P10-IT and PISi-T meant the formation of silicon-oxygen bonds, that is, the silica network. The FTIR absorption spectra have been explained elsewhere [23] and details are not provided in the present work.

In order to find whether the ICTEOS reacted with the hydroxyl groups on PAA, we subtracted the absorption spectrum obtained after imidization in case of films where ICTEOS was added to hydroxy PAA film (PI-P10-I) from the hydroxy PAA film (PI-P10). This spectrum is shown in Figure 2. The absence of absorption in the region 2250 cm⁻¹ due to isocyanato groups and appearance of urethane linkage at 1743 cm⁻¹ show that ICTEOS has reacted (see Figure 1) with the pendant hydroxyl groups on the polymer chain. The absorption in the region 2840–2920 cm⁻¹ and at 1234 cm⁻¹ due to −CH₂−CH₂− linkage and Si−C bonds, respectively, further confirms that ICTEOS has become the part of polymer chain. The presence of small peaks at 1179 cm⁻¹ and at 971 cm⁻¹ shows the presence of Si−O−R linkages, that is, the alkoxy groups of the ICTEOS. As the sol-gel process was not carried out with these experimental systems, purely made for FTIR analysis, so these groups remain partially unhydrolyzed/unchondensed in the matrix. The above results clearly show the successful binding of ICTEOS on the polymer chain which could further link the silica network with the matrix.

3.2. Morphological studies

The scanning electron micrographs showing the effect of silica loading and reinforcement binding with matrix on the morphology of the resulting hybrids are given in Figure 3. The micrographs in Figures 3(a) and 3(b) show the morphology of the unbonded hybrids with 20 and 40 wt% of silica, respectively, in the matrix. The silica particles are seen as white beads with round or oval shape and sharp boundaries. The average diameter of the particles increased from 0.2 to 8 micrometers as the silica contents were increased from 5 to 40 wt%. The sharp, clear boundaries of the silica particles with some interfacial spaces show that the pure organic and inorganic phases had poor interaction and as the silica loading increased the tendency towards phase separation increased. The micrographs in Figures 3(c) and 3(d) show the morphology of the PISi-P5-I-T hybrids with 20 and 40 wt% silica loading, respectively, in the matrix. Though with increased silica loading, the tendency of the particle size to increase remains there, however, there was a considerable
decrease in the particle size as compared to the unbonded hybrids. The diameter of the silica particles varied from 10 nm to 200 nm in these hybrids for silica loading varying from 5 to 40 wt%, respectively. The bonded hybrid system displayed a more adhesive interface between enforcement and the matrix thus leading to a homogenous distribution of silica particles and retarding their phase separation from the matrix. The micrographs in Figures 3(e) and 3(f) show the morphology of PISi-P10-I-T hybrids. As seen from these graphs, the increased extent of binding between the phases has further reduced the particle diameter which varies from 5–100 nm for the similar silica loading as stated above. The presence of alkoxy groups on the PI matrix and their co-condensation with TEOS to produce silica network during the sol-gel process has retarded the tendency of silica network to agglomerate into large particles thus reducing their size to nanolevel and making the distribution of the inorganic network more homogenous. The finer silica particles in the matrix with enhanced adhesion between the phases which improved the transparency of the hybrid films can also have great influence on the thermal mechanical properties of the hybrid material.

### 3.3. Visco-elastic properties

The temperature variation of storage modulus ($E'$) and tan $\delta$ (where tan $\delta$ is the loss factor related to the ratio of loss modulus to storage modulus) for the three hybrid systems studied is shown in Figures 4–6. The visco-elastic data have been given in Table 1. Incorporating silica in the matrix increased the storage modulus and high temperature reliability of the PI. Table 1 gives the values of storage modulus for different silica contents at two different temperatures for the studied hybrid systems. The increase in the modulus values as compared to the pure polymer is more in case of bonded hybrids.
It also depends on the degree of interphase bonding and the values obtained are higher in PISi-P10-I-T hybrids as compared to PISi-P5-I-T system (Table 1). As the temperature is increased, the modulus drops to about an order of magnitude in the rubbery region in case of pure PI. The modulus decreases linearly with temperature up to about 340°C and at T_g a rapid decrease in E’ is witnessed. The hybrid samples with different silica contents all have higher E’ values in the rubbery region as compared to the pure PI. The rate of decrease of E’, however, is considerably lower with large silica loading. The chemically bonded hybrids tend to retain the modulus values at higher temperature above 425°C than as compared to the unbonded system (Table 1).

The magnitude of the tan δ curves decreases with increasing the amount of silica (Figures 4–6). This suggests that the mobility of the polymer chains is restricted due to presence of silica in the matrix and the material show more elastic behavior as the tendency to viscous flow behavior is reduced. A comparison of the variation of tan δ with temperature for the unbonded and bonded hybrids shows that the bonded hybrids have much lower values of tan δ for the similar silica loading. The T_g associated with α-relaxation measured from the maxima of the tan δ curve (Table 1) for the unbonded hybrids with 40 wt% silica shows an increase of 5°C from the pure PI (Figure 4). The peak temperature of tan δ is shifted slightly to higher temperature with increasing silica. On the other hand, for the PISi-P5-I-T hybrids an increase of about 22°C in the T_g was observed with increasing silica contents from zero to 40 wt%. As the number of hydroxyl groups on the PI chains was increased, the T_g of the pure matrix was also shifted to the higher temperature. This is due to intermolecular bonding of the polymer chain due to presence of polar groups. The T_g recorded for the pure polymer used in case of PISi-P10-I-T hybrids was 403°C. The maximum value of 422°C was recorded in this case with 40% silica in-

clusion in the matrix (Figure 6). The large reduction in the tan δ curves and increase in T_g (Figure 7) for these hybrids can be attributed to the strong interaction/presence of covalent bonding between PI and silica. The Interfacial interaction also reduces the tendency of network structure to agglomerate into large silica particles which are reduced to almost nanolevel. These particles have high surface to volume ratio. More surface area available to bond/absorb the polymer chains for given silica content make the polymer chains stiffer. This also explains why the bonded hybrids with finer morphology had higher modulus values than that of the unbonded hybrids for the similar silica loading.
Table 1: Viscoelastic properties of polyimide-silica hybrids.

<table>
<thead>
<tr>
<th>SiO₂ (wt %)</th>
<th>Storage modulus (GPa) at 100°C</th>
<th>Storage modulus at 425°C</th>
<th>Tg (°C)</th>
<th>Tan delta (δ)</th>
</tr>
</thead>
<tbody>
<tr>
<td></td>
<td>PISi-P5-I-T</td>
<td>PISi-P10-I-T</td>
<td>PISi-P5-I-T</td>
<td>PISi-P10-I-T</td>
</tr>
<tr>
<td>0</td>
<td>1.34</td>
<td>1.83</td>
<td>1.87</td>
<td>0.13</td>
</tr>
<tr>
<td>5</td>
<td>1.72</td>
<td>2.04</td>
<td>2.04</td>
<td>0.20</td>
</tr>
<tr>
<td>10</td>
<td>1.81</td>
<td>2.20</td>
<td>2.34</td>
<td>0.23</td>
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<td>40</td>
<td>2.48</td>
<td>3.33</td>
<td>4.24</td>
<td>0.33</td>
</tr>
</tbody>
</table>

Figure 7: Variation of glass transition with silica content in polyimide-silica hybrids: PISi-T (●), PISi-P5-I-T (▼), PISi-P10-I-T (△).

3.4. Thermal mechanical analysis

Figure 8 shows linear thermal expansion for pure PI, hydroxy PI and the chemically bonded PI-silica hybrids as function of temperature. The value of coefficient of thermal expansion for the pure PI is 52.1 ppm/°C at 50°C. The average value in the temperature range of 50–300°C was measured as 61.42 ppm/°C. Beyond this temperature softening of the polymer chain may be taking place. Our value is in agreement with the values of 55 ppm/°C reported by Yano et al. [24] at 150°C and 48.5 ppm/°C reported by Southward et al. [25] at 50°C. The reduction in the CTE value of PI was observed with the introduction of hydroxyl groups on the chain and the average value for the hydroxyl PI was 56.88 ppm/°C. In case of hybrid film PISi-P5-I-T with 40 wt% silica, the CTE values were reduced to 24.03 ppm/°C. Also the softening point is increased to higher temperature. The CTE of hybrid materials is dependent upon matrix, type of reinforcement, and volume fraction of the reinforcement and interaction between the phases. In case of PI-Si-P10-I-T hybrids where there is more bonding between the matrix and the silica network, the average CTE value recorded was 20.46 ppm/°C. PIs are commonly used in microelectronic industry as interlayer dielectrics for thin film wiring in multichip packages. To meet the stringent demands of industry, the material properties such as CTE has to be controlled precisely. Most of the low dielectric PIs have undesirable high values of CTE which may result in fatal damage from thermal stresses generated due to the mismatch between the semiconductor chip and insulating PI. Such hybrids material therefore can be extremely useful in such applications requiring a controlled CTE.

3.5. Thermal stability

The TGA thermograms of the three hybrid systems, PISi-T, PISi-P5-I-T, and PISi-P10-I-T with various silica contents,
are shown, respectively, in Figures 9, 10, and 11. The decomposition temperature of the pure PI was around 650°C. Slight decrease in the weight at lower temperature for the hybrids could be due to the loss of by-products (H2O, EtOH) from the condensation reaction of the silica network. The hydroxy PI used for preparing the bonded hybrids show slightly higher thermal decomposition temperature than the PI used for the unbonded hybrids. It seems that the presence OH groups on the polymer chain act as free radical quencher during the oxidative degradation process. As the amount of silica is increased in the matrix, the thermal decomposition behavior shows a gradual weight loss with increasing temperature up to 770°C. The effect is more pronounced in the hybrids where higher silica loading have been used in the matrix. Since the formed silica network exhibits good thermal stability even at 800°C, the weight loss of the hybrids is resulting mainly from the PI matrices. It seems that the polymer chains absorbed or trapped in the network are protected from thermo-oxidative process and this hinders the process of degradation. The PI hybrids therefore show slightly better thermal stability as compared to the matrix. The weight retained above 770°C in all the hybrids was found proportional to the silica contents used in the matrix, meaning thereby that the sol-gel process was carried out almost completely in the present studies.

4. CONCLUSIONS

The present studies on PI-Silica hybrids show that interphase chemical links between the silica network and the polymer chain prevent the agglomeration of silica particles, reduce the particle size to nanolevel thus making their distribution more homogenous in the matrix. The improved interfacial interaction between the phases enhances the mechanical strength particularly at high temperatures. The glass transition temperature of the polymer is increased more with addition of silica in these systems as compared to the one where no bonding exists between the phases. The values of coefficient thermal expansion are greatly reduced and thermal stability of the material is enhanced. Chemically bonded polyimide-silica nanocomposites thus show better mechanical and thermal properties.

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